Part Number Customer					
Category	Parameter		Specification	Measurement Method	
OverallWafer	1.0	Diameter	150.00 +/- 0.50 mm	Wafer Vendor	
	2.0	Primary Flat Orientation	{110}+/-0.5 degree	Wafer Vendor	
	3.0	Primary Flat Length	57.50 +/- 2.50 mm	Wafer Vendor	
	4.0	Secondary Flat Orientation	none		
	5.0	Edge Rounding	Semi M1	Wafer Vendor	
	6.0	Overall Thickness	460.50 +/- 6.00 μm	ADE, 100%	
	7.0	Total Thickness Variation (TTV)	<3.00µm	Guaranteed by Process	
	8.0	Global Flatness (TIR)	<3.00um	ADEmeasurement 100%	
	9.0	Bow	<100.00µm	ADE to ASTM F534, 20%	
	10.0	Warp	<100.00µm	ADE to ASTM F657, 20%	
	11.0	Edge Chips	0	Bright Light, 100% (note 2)	
	12.0	Edge Exclusion	5mm		
HandleSilicon	13.0	Handle Growth Method	CZ	Wafer Vendor	
	14.0	Handle Orientation	{100} +/- 1 degree	Wafer Vendor	
	15.0	Handle Doping Type	Any	Wafer Vendor	
	16.0	Handle Dopant	Any	Wafer Vendor	
	17.0	Handle Resistivity	>1 Ohmem	Wafer Vendor	
	18.0	Handle Thickness	450.00 +/- 5.00 um	ADE, 100%inspection	
	19.0	Backside Finish	Lapped with oxide and laserwith mask	Guaranteed by Process	
BuriedOxide	24.0	Oxide Type	Thermal	Guaranteed by process	
	25.0	Oxide formed on	Device and handle wafers	Guaranteed by process	
	26.0	Oxide Thickness	10,000.00 +/- 500.00 A	Nanospec centre point, 4%	
DeviceSilicon	33.0	Device Growth Method	CZ	Wafer Vendor	
	34.0	Device Orientation	{100} +/- 0.5 degree	Wafer Vendor	
	35.0	Device Doping Type	Ν	Wafer Vendor	
	36.0	Device Dopant	Phosphorous	Wafer Vendor	
	37.0	Device Resistivity	1 - 3 Ohmem	Wafer Vendor	
	38.0	Nominal Thickness	9.00 +/- 0.75 um	FTIR or Filmetrics 9 point measurement	
	39.0	Distance to device silicon edge from wafer edge	<2mm	Guaranteed by process	
	40.0	Surface	roughness < 3A rms	Guaranteed by process	
	41.0	Voids	none inside 5mm edge exclusion	Bright Light inspection 100%	
	42.0	Scratches	none	Bright Light inspection 100%	
	43.0	Haze	none	Bright Light inspection	
	44.0	Device Field Oxidation	5,000.00 +/- 250.00 A	Nanospec	

Icemos Technology Ltd

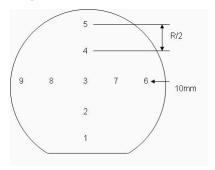
Product Specification

1001.554601

Part Number		Customer		
Category	Parameter	Specification	Measurement Method	
Shipping Details	Wafer per box :	Max 25		
	Packaging :	Taped Polypropylene Wafer Box Empak, Ultrapak, 150.00mm Antistatic Double Bagging		
	Lot Shipment Data	Device Thickness Bow / Warp Data Handle and SOI Thickness		
Explanatory Notes	1. Microscope inspec	tion performed using microscope scan as below. 5x objective.		

2. All bright light inspections performed exclude all wafer area outside the edge exclusion defined in Overall Wafer, Edge Exclusion. High intensity bright lamp inspection as per ASTM F523.

3. 9 point measurement are as shown in the diagram below:



Additional Information